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Applicant

SHAHAB et al

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U.S. PATENT DOCUMENTS

[illegible]

FOREIGN PATENT DOCUMENTS

[illegible]

OTHER DOCUMENTS (including Author, Title, Date, Pertinent pages, etc.)

	Sanders et al, "Self-segregating materials for immersion lithography", Advances in Resist Materials and Processing Technology XXV, Proc. of SPIE Vol. 6923, 692309 (2008).
	http://www.dic.co.jp/en/products/fluoro/additive/appli.html

*Examiner		Date Considered	
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Examiner: Initial if reference considered, whether or not citation is in conformance with MPEP 609; Draw line through citation if not in conformance and not considered. Include copy of this form with next communication to applicant.